



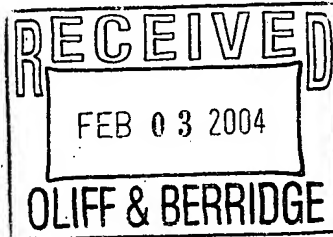
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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/686,634	10/17/2003	2811	1280	104741.01	24	34	6

25944  
OLIFF & BERRIDGE, PLC  
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ALEXANDRIA, VA 22320



CONFIRMATION NO. 8919

## FILING RECEIPT



\*OC000000011802091\*

Date Mailed: 02/02/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

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## Assignment For Published Patent Application

Seiko Epson Corporation, Tokyo, JAPAN;

## Domestic Priority data as claimed by applicant

This application is a CON of 09/423,969 11/17/1999 ABN  
which is a 371 of PCT/JP99/01327 03/17/1999

## Foreign Applications

JAPAN 10-67508 03/17/1998  
JAPAN 11-32123 02/10/1998

1999

Projected Publication Date: To Be Determined - pending completion of Security Review

Non-Publication Request: No

Early Publication Request: No



**Title**

Method of forming thin film patterning substrate including formation of banks

**Preliminary Class**

257

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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**PATENT APPLICATION**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Sunichi SEKI et al.

Application No.: 10/686,634

Docket No.: 104741.01

Filed: October 17, 2003

For: METHOD OF FORMING THIN FILM PATTERNING SUBSTRATE INCLUDING  
FORMATION OF BANKS

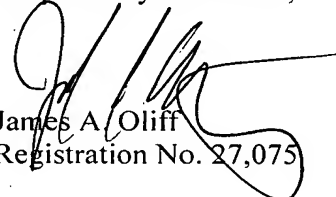
**REQUEST FOR CORRECTION OF PALM RECORDS**

Commissioner for Patents  
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Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,



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JAO:JSA/tje

Date: February 10, 2004

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